Crystallization kinetics and corrosion behaviors of Mg$_{61}$Cu$_{28}$Gd$_{11}$ and (Mg$_{0.61}$Cu$_{0.28}$Gd$_{0.11}$)$_{99.5}$Sb$_{0.5}$ amorphous alloys

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Abstract: 0.5% (molar fraction) Sb was added to Mg$_{61}$Cu$_{28}$Gd$_{11}$ glass forming alloy to improve its thermal stability and corrosion resistance. The crystallization kinetics of Mg$_{61}$Cu$_{28}$Gd$_{11}$ and (Mg$_{0.61}$Cu$_{0.28}$Gd$_{0.11}$)$_{99.5}$Sb$_{0.5}$ amorphous alloys was investigated under continuous heating. The temperatures of glass transition, onset and peak crystallization for the two glasses exhibit strong heating-rate dependence. The activation energies for the onset and peak crystallization were determined based on the Oawza plots. Vogel-Fulcher-Tamman equation analysis shows that the larger strength parameter and much longer relaxation time are obtained due to the Sb addition. The corrosion properties of the two glassy alloys were studied by means of potentiodynamic and immersion tests. Compared with the parent alloy, (Mg$_{0.61}$Cu$_{0.28}$Gd$_{0.11}$)$_{99.5}$Sb$_{0.5}$ glassy alloy exhibits a superior corrosion resistance in Cl$^-$-containing alkaline solution, as indicated by the lower passive current density and corrosion rate. Based on the point defect model, the effect mechanism of Sb addition on corrosion resistance of Mg-Cu-Gd glassy alloy is carefully identified.

Key words: Mg-based bulk metallic glasses; Sb; crystallization kinetics; corrosion resistance

1 Introduction

Mg-based bulk metallic glasses (BMGs) have attracted increasing interest during the last decade due to their high specific strength and relatively low cost. Among them, Mg-TM-RE (TM: transition metal; RE: rare-earth metal, such as Y and Gd) alloy system has been known to exhibit a large supercooled liquid region (SLR) and high glass-forming ability (GFA) [1−4]. Ever since the first search that discovered Mg$_{65}$Cu$_{25}$Y$_{10}$ BMG with a size of 4 mm in diameter, a great deal of effort has been devoted to develop Mg-based BMGs [5−8]. Recently, ZHENG et al [9] reported that the best ternary Mg-based glassy former has been found in the composition of Mg$_{64}$Cu$_{23}$Gd$_{11}$ with the maximum size up to 12 mm in diameter. The follow-up investigations on the Mg-Cu-Gd-based BMGs have been directed to the addition of a proper element to improve its GFA and other properties, such as Mg-Cu-B-Gd, Mg-Cu-Gd-Be, Mg-Cu-Ag-Gd-Ni, Mg-Cu-Gd-Nb and Mg-Cu-Ag-Gd [10−15]. In particular, the addition of silver seems to result in the best GFA, and the critical diameter of Mg$_{64}$Cu$_{23}$Ag$_{13}$Gd$_{11}$ glassy alloys has achieved 25 mm by a Cu-mold injection casting method [15]. As promising engineering materials, the thermal stability (i.e. crystallization resistance) and corrosion resistance of Mg-based BMGs are usually considered the important aspects for their application, and thus have received great attention in recent years.

To date, the addition of quaternary element is an effective method to improve the crystallization resistance of Mg-Cu-RE (RE=Y, Gd) glassy alloy. CHENG et al [16] have studied the effect of B addition on crystallization kinetics of Mg$_{65}$Cu$_{25}$Y$_{10}$ glassy alloy, and confirmed that the minor B element appears to enhance the thermal stability of Mg-Cu-Y-B alloy. CHANG et al [17] have investigated the crystallization processes of Mg$_{65}$Cu$_{22.5}$Y$_{10}$ glassy alloy, and confirmed that the minor B element appears to enhance the thermal stability of Mg-Cu-Y-B alloy. CHANG et al [17] have investigated the crystallization processes of Mg$_{65}$Cu$_{22.5}$Gd$_{10}$ glassy alloy with Ag addition. It has been found that the activation energy of crystallization is increased by minor addition of Ag, and the main crystallization process for Mg$_{65}$Cu$_{22.5}$Gd$_{10}$Ag$_{2.5}$ glassy alloy is governed by diffusion controlled crystal growth with decreasing nucleation rate [17]. As can be seen, both B and Ag elements have negative heat of mixing ($\Delta H_m$) with the main constitutes of Mg-Cu-Y/Gd glassy alloys [18]. However, Sb element which exhibits partial positive $\Delta H_m$ with main constitutes has not been
previously reported to improve the thermal stability of Mg-Cu-Gd glassy alloy.

In addition, corrosion behavior of Mg-Cu-RE (RE=Y, Gd) BMGs has been also investigated in recent years. QIN et al[19] conducted corrosion tests of Mg65Cu25Gd10 in 0.2 mol/L H3BO3/Na2B4O7 (pH=8.4), 0.02 mol/L NaCl (pH=11) and 0.1 mol/L NaOH (pH=13) solutions, and found that Mg65Cu25Gd10 BMGs showed higher corrosion resistance than its crystalline counterpart. Moreover, in Cl−-containing alkaline solution, both amorphous and crystalline Mg65Cu25Gd10 alloys are active dissolved at high current density due to the presence of aggressive Cl− ion in the solution[19]. Similar results have also been found in Mg-Cu-Y glassy alloys[20−21]. To date, there is still lack of study for the improvement of corrosion resistance by microalloying technique in Mg-Cu-Gd alloy system within Cl−-containing alkaline solution.

This work aims to investigate the crystallization and corrosion behaviors of Mg61Cu28Gd11 and (Mg0.61Cu0.28Gd0.11)99.5Sb0.5 BMGs and explore the effect mechanism of minor addition of Sb on thermal stability and corrosion resistance of Mg-Cu-Gd glassy alloy by the differential scanning calorimetry (DSC) technique and electrochemical measurements.

2 Experimental

Elements with purity better than 99.9% were used as starting materials. Since the boiling points of Mg and Sb are lower than those of Cu and Gd, Cu-Gd as intermediate alloy was melted prior to be re-melted with Mg and Sb in an arc furnace under an argon atmosphere. The glasses were prepared by copper mold casting with a diameter of 2 mm and a length of 50 mm. The structures of the samples obtained were examined by X-ray diffractometer (XRD, Bruker D8) with Cu Kα radiation. The crystallization process of the Mg61Cu28Gd11 and (Mg0.61Cu0.28Gd0.11)99.5Sb0.5 amorphous alloys were characterized by continuous heating in a DSC (Perkin-Elmer DSC 7) under flowing high purity argon. A set of DSC scans was recorded at heating rates ranging from 10 to 80 K/min. The corrosion behavior was evaluated by electrochemical measurements. The electrolyte used was 0.01 mol/L NaCl solution with pH 12 (adjusted by 1 mol/L NaOH). Electrochemical measurements were conducted in a three-electrode cell using a platinum counter electrode and a saturated calomel reference electrode (SCE). Potentiodynamic polarization curves were measured with a potential sweep rate of 1 mV/s in the solution open to air at room temperature after immersing the specimens for about 20 min. Electrochemical impedance spectroscopy (EIS) was also measured at open-circuit potential in the solution. The frequency range used was from 10^2 to 10^2 Hz, with an amplitude perturbation of 5 mV. The mass loss measurements of the glassy alloys were conducted in 0.01 mol/L NaCl alkaline solution after immersing for 100 h. Corrosion effects on the surface topography of immersed specimens were studied by scanning electron microscopy (SEM).

3 Results and discussion

3.1 Microstructures

Fig.1 shows the XRD patterns of as-prepared Mg61Cu28Gd11 and (Mg0.61Cu0.28Gd0.11)99.5Sb0.5 glassy alloys. The diffraction patterns consist only of broad diffraction peaks in the 2θ range of 32°−42°, indicating the formation of a single glassy phase.

![Fig.1 XRD patterns of as-prepared (Mg0.61Cu0.28Gd0.11)100−xSb0 BMGs (x = 0, 0.5) BMGs](image)

3.2 Crystallization kinetics

Fig.2 shows the DSC curves for Mg61Cu28Gd11 and (Mg0.61Cu0.28Gd0.11)99.5Sb0.5 glassy alloys obtained at various heating rates of 10, 20, 30, 40 and 80 K/min. The values of glass transition temperature Tg, onset temperature of crystallization Tc, peak temperatureTp and ΔTc (defined as temperature region between Tg and Tc) shift to higher temperatures with increasing the heating rate, as shown in Fig.3. The crystallization of samples is rate dependent caused by the fact that nucleation is a thermally activated process, whereas the rate dependence of the kinetic glass transition is due to the relaxation processes in the glass transition region[22]. The effective activation energy of crystallization processes can be calculated by means of the Ozawa equation[23−24]:

\[ \ln \phi = -\frac{E}{RT} + \text{constant} \]

where \( \phi \) is the heating rate; \( R \) is the molar gas constant; \( T \) represents the thermodynamically characteristic
temperature, such as $T_x$ or $T_p$. The plots of $\ln \phi$ against $1/T$ yield an approximate straight line with a slope of $E_x$ and $E_p$, as shown in Fig.4, in which $E_x$ is the effective activation energy for the onset temperature of crystallization, and $E_p$ is the effective activation energy for the peak temperature. Thus, we obtained $E_x=81$ kJ/mol, $E_p=89$ kJ/mol for Mg$_{61}$Cu$_{28}$Gd$_{11}$ glassy alloy, and $E_x=106$ kJ/mol, $E_p=111$ kJ/mol for (Mg$_{0.61}$Cu$_{0.28}$Gd$_{0.11}$)$_{99.5}$Sb$_{0.5}$ glassy alloy. $E_x$ and $E_p$ of Sb-containing alloy are about 31% and 25% higher, respectively, than those of the parent alloy, suggesting the improvement of crystallization resistance in (Mg$_{0.61}$Cu$_{0.28}$Gd$_{0.11}$)$_{99.5}$Sb$_{0.5}$ glassy alloy.

The dependence of the glass transition temperature $T_g$ on the heating rate $\phi$ could be evaluated in terms of Vogel-Fulcher-Tamman (VFT) equation written in the form [25]:

$$\phi = B \exp \left[ \frac{DT_g^0}{T_g^0 - T_g} \right]$$

where $T_g^0$ is the asymptotic value of onset glass transition $T_g$ when the cooling or heating rate is infinitely slow; $B$ is the relaxation time dimension under the ideal state; and $D$ is the strength parameter. Based on Eq.(2), we obtained three adjustable parameters: $B$, $D$, and $T_g^0$, as listed in Table 1. Fig.5 shows the best VFT fitting curves of the two glassy alloys. As can be seen, $B$ and $D$ parameters of Sb-containing alloy are both considerably higher.
larger than those of the parent alloy while the value of $T_g^0$ is slightly smaller, indicating the increase of strength and relaxation time in (Mg$_{0.61}$Cu$_{0.28}$Gd$_{0.11}$)$_{99.5}$Sb$_{0.5}$ glassy alloy.

The local activation energy $E_c(x)$ usually indicates the potential barrier that is overcome during the transformation of amorphous to crystallized phase. Its variation with crystallized fraction $x$ reflects the nucleation and growth behavior in the crystallization process. In order to calculate local activation energy, crystallized fraction $x$ as functions of temperature $T$ at different heating rates for Mg$_{61}$Cu$_{28}$Gd$_{11}$ and (Mg$_{0.61}$Cu$_{0.28}$Gd$_{0.11}$)$_{99.5}$Sb$_{0.5}$ glassy alloy are plotted in Figs.6(a) and (b), respectively. From the following equation, suggested by Ozawa-Flynn-Wall for non-isothermal crystallization, the local activation energy for crystallization $E_c(x)$ can be evaluated [26]:

$$\ln \phi = -1.0516 \frac{E_c(x)}{RT(x)} + \text{constant}$$  \hspace{1cm} (3)

where $E_c(x)$ is local activation energy and $T(x)$ is the temperature corresponding to the certain crystallized volume fraction, $x$, at different heating rates. From Eq.(3), for a given $x$, $T$ values of different heating rates are determined. $E_c(x)$ can be calculated by the slope of $\ln \phi$ against $1/T(x)$ curve. Fig.6(c) shows the plots of $E_c(x)$ as a function of $x$ for the two glassy alloys. Note that, Mg$_{61}$Cu$_{28}$Gd$_{11}$ and (Mg$_{0.61}$Cu$_{0.28}$Gd$_{0.11}$)$_{99.5}$Sb$_{0.5}$ alloys exhibit the similar tendency of the variation of $E_c(x)$ with increasing $x$. At the beginning, the values of $E_c(x)$ are 81 kJ/mol and 106 kJ/mol, respectively for Mg$_{61}$Cu$_{28}$Gd$_{11}$ and (Mg$_{0.61}$Cu$_{0.28}$Gd$_{0.11}$)$_{99.5}$Sb$_{0.5}$ glassy alloys. Subsequently, $E_c(x)$ values increase slowly with $x$ during the very initial crystallization stage and reach the maximum values at $x=0.2$, to be 103 kJ/mol and 131 kJ/mol, respectively, for the above alloys. Then, $E_c(x)$ values decrease drastically in the subsequent crystallization process and remain 60 kJ/mol and 67 kJ/mol at $x=0.95$, respectively, for the parent and Sb-containing alloys. The variation of $E_c(x)$ with $x$ can be attributed to the nucleation and growth behaviors at different stage of crystallization process. In the early stage of crystallization, the nucleation and growth of micro-grains need to overcome larger potential barrier, which would further increase with the increase in temperature. However, when the crystallized volume fraction achieves a certain point at $x=0.2$, the potential barrier would not increase due to the structural relaxation of amorphous phases surrounding the crystal phases. On the other hand, the Sb-containing alloy exhibits higher $E_c(x)$ value during the whole crystallization process, indicating that the crystallization resistance as well as thermal stabilities is improved by minor addition of Sb. This is in consistent with the result of Owza methods. The better thermal stability obtained by Sb-containing
glassy alloy could be attributed to multiple factors. The larger overall atomic size difference (the atomic size ratios: 0.899 for Sb/Mg, 0.889 for Cu/Sb and 0.809 for Sb/Gd) and higher overall electronegativity difference would induce the increment of packing density of \((\text{Mg}_{0.61}\text{Cu}_{0.28}\text{Gd}_{0.11})_{99.5}\text{Sb}_{0.5}\) alloy in supercooled liquid. In addition, the strong affinity for Sb/Mg \((\Delta H_m=-16\text{ kJ/mol})\) and Sb/Gd \((\Delta H_m=-68\text{ kJ/mol})\) \([18]\), together with the weak repellency for Sb/Cu \((\Delta H_m=7\text{ kJ/mol})\) will even impose resistance to the formation of the major Mg\(_2\)Cu phase, possibly by blocking the path of Mg and Cu diffusion. Thus, the crystallization energy barrier would be increased indirectly, which could result in the final improvement of crystallization resistance in Sb-containing glassy alloy.

3.3 Electrochemical results

Fig. 7(a) shows the polarization curves of \((\text{Mg}_{0.61}\text{Cu}_{0.28}\text{Gd}_{0.11})_{100-x}\text{Sb}_x\) \((x=0, 0.5)\) glassy alloys in 0.01 mol/L NaCl solution with pH 12. The corrosion data, including the corrosion potential \((\varphi_{\text{corr}})\), current density \((J_{\text{corr}})\), the passive potential \((E_p)\) and passive current density \((J_p)\) are summarized in Table 2. It can be seen that the parent and Sb-containing alloys both exhibit a high corrosion potential and low corrosion current density, implying the excellent corrosion resistance of Mg-Cu-Gd glassy materials. In addition, the minor addition of Sb element results in a positive and significant shift of the corrosion potential by about 277 mV. The corrosion current density of the Sb-containing alloy \((0.130\mu\text{A/cm}^2)\) is even lower than that of the parent alloy \((32.3\mu\text{A/cm}^2)\). Furthermore, as compared with the parent alloy, the Sb-containing alloy exhibits a better passivation in 0.01 mol/L NaCl alkaline solution.
Table 2 Corrosion data obtained from potentiodynamic polarization curves and immersion test in 0.01 mol/L NaCl alkaline solutions (pH 12) at open-circuit potential for two glassy alloys

<table>
<thead>
<tr>
<th>Sample</th>
<th>$\phi_{corr}$/mV</th>
<th>$J_{corr}$/($\mu$A·cm$^{-2}$)</th>
<th>$J_p$/($\mu$A·cm$^{-2}$)</th>
<th>$E_p$/mV</th>
<th>$R_{corr}$(mm·a$^{-1}$)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Mg$<em>{61}$Cu$</em>{28}$Gd$_{11}$</td>
<td>−573.4</td>
<td>32.3</td>
<td>138.1</td>
<td>−492.3</td>
<td>0.119</td>
</tr>
<tr>
<td>(Mg$<em>{0.61}$Cu$</em>{0.28}$Gd$<em>{0.11}$)$</em>{99.5}$Sb$_{0.5}$</td>
<td>−296.1</td>
<td>0.1</td>
<td>11.4</td>
<td>−188.4</td>
<td>0.049</td>
</tr>
</tbody>
</table>

with extremely lower passive current density (11.4 μA/cm$^2$), which is about a tenth of that of the parent alloy. However, when the anodic voltage increases to 0.386 V, the corrosion current density of Sb-containing alloy abruptly increases to the order of $10^{-2}$ A/cm$^2$ due to the breakdown of the passive film.

From Fig.7(b), it can be noticed that EIS of both Mg$_{61}$Cu$_{28}$Gd$_{11}$ and (Mg$_{0.61}$Cu$_{0.28}$Gd$_{0.11}$)$_{99.5}$Sb$_{0.5}$ glassy alloys in Cl$^-$-containing alkaline solution show only one capacitive loop, meaning that the corresponding electrode process contains only one time constant and the minor addition of Sb does not change the corrosion mechanism of the parent alloy. In addition, the single capacitive loop also indicates the formation of uniform passive films in the two glassy alloys. On the other hand, the larger impedance of (Mg$_{0.61}$Cu$_{0.28}$Gd$_{0.11}$)$_{99.5}$Sb$_{0.5}$ glassy alloy implies that the introduction of Sb in Mg-Cu-Gd glassy alloy increases its polarization resistance and further decreases the electrochemical charge of interfacial reaction. This is in good agreement with the potentiodynamic polarization result in Fig.7(a).

The corrosion rates of the two glassy alloys could be calculated from the mass loss measurement in 0.01 mol/L NaCl alkaline solution at 298 K, as listed in Table 2. The Sb-containing alloy exhibits much lower corrosion rate (0.049 mm/a) than the parent alloy (0.119 mm/a). The SEM micrographs of the two glassy alloys after immersing in 0.01 mol/L NaCl alkaline solution for 100 h are shown in Fig.8. Compared with Mg$_{61}$Cu$_{28}$Gd$_{11}$ glassy alloy, the surface morphology of the Sb-containing alloy is much more homogeneous and smooth, no obvious pitting attacks occur. The better corrosion resistance of (Mg$_{0.61}$Cu$_{0.28}$Gd$_{0.11}$)$_{99.5}$Sb$_{0.5}$ glassy alloy can be attributed to the higher standard electrode potentials (−0.66 V) of Sb addition in alkaline solution compared with Mg and Gd. This would result in a nobler state of the Sb-containing glassy alloy and thus increase the corrosion resistance of Mg-Cu-Gd BMGs.

Based on the “point defect model, PDM” theory[27], the corrosion mechanism of Sb-containing alloy can be further explained. Fig.9 shows the physico-chemical processes that occur within a passive film according to the PDM theory[27–28]. During the growth of passive film, cation vacancies $V_M^{\prime}$ are first formed at the film/solution (F/S) interface, but then will be consumed at the metal/film (M/F) interface, while the anion vacancies $V_O^{\prime}$ are on the opposite. The oxygen-ions from the F/S will diffuse continuously into M/F and result in the initial growth of passive film. Thus, at the beginning of anodic reaction in the Cl$^-$-containing alkaline solution, the Sb element can be presumed to be Sb$^{3+}$ cations at the M/F interface, and then are oxidized to be Sb$^{5+}$ cations at the F/S interface. Subsequently, the...
cations will be separated from the outer layer of passive film and enter into the alkaline solution. This would result in the formation of high valence vacancies in the described as follows:

\[
\text{M/F: } \text{Sb} \rightarrow \text{Sb}^{3+} + V_{\text{O}}^0 + 3e \tag{4}
\]

\[
\text{F/S: } \text{Sb}^{3+} \rightarrow \text{Sb}^{5+} + 2e \tag{5}
\]

\[
\text{Sb}^{5+} + 6OH^- \rightarrow [\text{Sb(OH)}_6]^2^- \tag{6}
\]

It should be noticed that the formation of oxygen-ions in Procedure (4) of Fig.9 is only suitable for the neutral and acidic solution. For the Cl\textsuperscript{−}-containing alkaline solution, Procedure (4) could be described as follows:

\[
\text{F/S: } V_{\text{O}} + 2OH^- \rightarrow O_2 + 2H_2O \tag{7}
\]

The diffusion of oxygen-ions is performed through the above electrochemical reactions (4)–(7). Based on the ion mobility equation proposed by FROMHOLD and COOK\textsuperscript{[29]} and high-field approximation, the concentration of oxygen-ions \(c'_o(x)\) can be determined as the following formulas:

\[
c'_o(x) = k_2 \left[ k_4^{-1} - \frac{n}{2D_0} \right] \exp(-x/a) + \frac{n}{2D_0} \tag{8}
\]

\[
D_0 = \frac{D_0}{2} \exp[2FaE/(RT)] \tag{9}
\]

where \(D_0\) is the diffusion coefficient of oxygen-ions in the passive film; \(E\) is electric field strength; \(a\) is ionic jump distance (\(a=3-10^{-6}\ cm\)); \(F\) is Faraday constant; \(R\) is molar gas constant; \(T\) is temperature; \(k_4(i=1, 2, 3, 4)\) is reaction rate constant. For the Sb-containing glassy alloy, the modified formula of oxygen-ions concentration can be determined as follows:

\[
c'_o(x) = (k_2 + k_{2,\text{Sb}}) \left[ k_4^{-1} - \frac{n}{2D_0} \right] \exp(-x/a) + \frac{n}{2D_0} \tag{10}
\]

By comparing Eqs.(8) with (10), the oxygen-ions concentration is increased apparently by the introduction of Sb. This may further accelerate the formation of oxides at the M/F interface, and then improve the growth of passive film.

4 Conclusions

1) The crystallization kinetics analysis shows that \(E_c\) and \(E_v\) of Sb-containing alloy are about 31% and 25% higher, respectively, than those of the parent alloy. The dependence of the glass transition on the heating rate was analyzed in terms of the VFT equation, and the superior strength parameter \(D\) and much longer relaxation time \(B\) were obtained for \((\text{Mg}_{0.61}\text{Cu}_{0.28}\text{Gd}_{0.11})_{99.5}\text{Sb}_{0.5}\) glassy alloy.

2) \(\text{Mg}_{61}\text{Cu}_{28}\text{Gd}_{11}\) and \((\text{Mg}_{0.61}\text{Cu}_{0.28}\text{Gd}_{0.11})_{99.5}\text{Sb}_{0.5}\) alloys exhibit the similar tendency of the variation of local activation energy \(E_c(x)\) with increasing the crystallized volume fraction \(x\). The Sb-containing alloy exhibits higher \(E_c(x)\) during the whole crystallization process, indicating that the crystallization resistance as well as thermal stabilities is improved by minor addition of Sb.

3) The results of potentiodynamic and immersion tests reveal that the minor addition of Sb could considerably enhance the corrosion resistance of the parent alloy in the Cl\textsuperscript{−}-containing alkaline solutions, as indicated by the lower corrosion current density, \(~0.130\ \mu A/cm^2\), and depressed corrosion rate, \(~0.049\ \text{mm/a}.\) Based on the PDM theory, the increase of oxygen-ions concentration at the M/F interface of Sb-containing alloy would accelerate the growth of passive film.

References


Mg$_{61}$Cu$_{28}$Gd$_{11}$ 和(Mg$_{0.61}$Cu$_{0.28}$Gd$_{0.11}$)$_{99.5}$Sb$_{0.5}$ 非晶合金的
晶化动力学和腐蚀行为

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摘 要: 研究 0.5% (摩尔分数) Sb 的引入对 Mg$_{61}$Cu$_{28}$Gd$_{11}$ 块体非晶合金性能的影响。利用差热扫描量热仪测试样品的晶化动力学。结果表明: 在等时加热的过程中, 非晶合金的玻璃转变温度、起始晶化和峰值晶化温度都表现出对加热速率强的依赖性。基于 Oawza 方法可以确定非晶合金的起始晶化和峰值晶化激活能。

Vogel-Fulcher-Tamman 公式分析表明: 含 Sb 元素的非晶合金具有更高的强度系数和更长的延迟时间。采用电化学极化和失重测试方法研究 2 种玻璃合金的腐蚀行为。与基体非晶合金相比, 添加微量 Sb 降低了非晶合金的在含 Cl$^-$ 的酸性溶液中的钝化电流密度和腐蚀速率, 表现出相比基体合金更为优越的耐蚀性。最后基于“点缺陷模型”进一步分析微量 Sb 元素对基体合金耐蚀性能的影响机理。

关键词: Mg 基大块金属玻璃; Sb; 晶化动力学; 耐蚀性

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